編號: 296

## 國立成功大學 109 學年度碩士班招生考試試題

系 所:環境醫學研究所

考試科目:作業環境測定

考試日期:0211,節次:3

## 第1頁,共1頁

※ 考生請注意:本試題不可使用計算機。 請於答案卷(卡)作答,於本試題紙上作答者,不予計分。

- 1. Please define following terminologies:
  - (1) Similar exposure group (5%)
  - (2) Static sampling (5%)
  - (3) Biological monitoring (5%)
  - (4) Exposure profile (5%)
- 2. (1) Please explain what is "chemical control banding (CCB)". (10%)
  - (2) What are the limitations while CCB is used for conducting exposure and health risk assessment? (10%)
- 3. (1) Based on the occupational health regulation in Taiwan, exposure modeling should be used for what kinds of chemicals under what situations? (10%)
  - (2) Please describe the vapor saturation model and its limitations while it was used for conducting exposure assessment. (10%)
- 4. If you are requested to assess workers' free silica exposures, please describe the sampling and analysis method which can be used for the above purpose. (20%)
- 5. Assuming a worker has exposed to chemical A as the followings:
  - Exposed conc.: 1mg/m<sup>3</sup>
  - Worker weight: 60kg
  - Breathing rate: 20 L/min
  - Contaminant permanently retained by the body: 50%
  - Job duration: 8h/day, 5 days/week, 48 weeks/year, 5 years
  - Chemical A absorption rate: 100%
  - (1) Please calculate worker's absorber dose per day, absorbed dose at the end of 5 years, potential dose per day, and potential dose at the end of 5 years. (10%)
  - (2) Please make any assumptions if you feel necessary for the above calculations. (10%)